

DIALS: integration

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ECM DIALS workshop August 2015



DIALS: integration

DATA FLOW



Internals: top-level

Tasks in `dials.integrate`:

Calculate the bounding box parameters from strong reflections



Predict the positions of reflections on the images



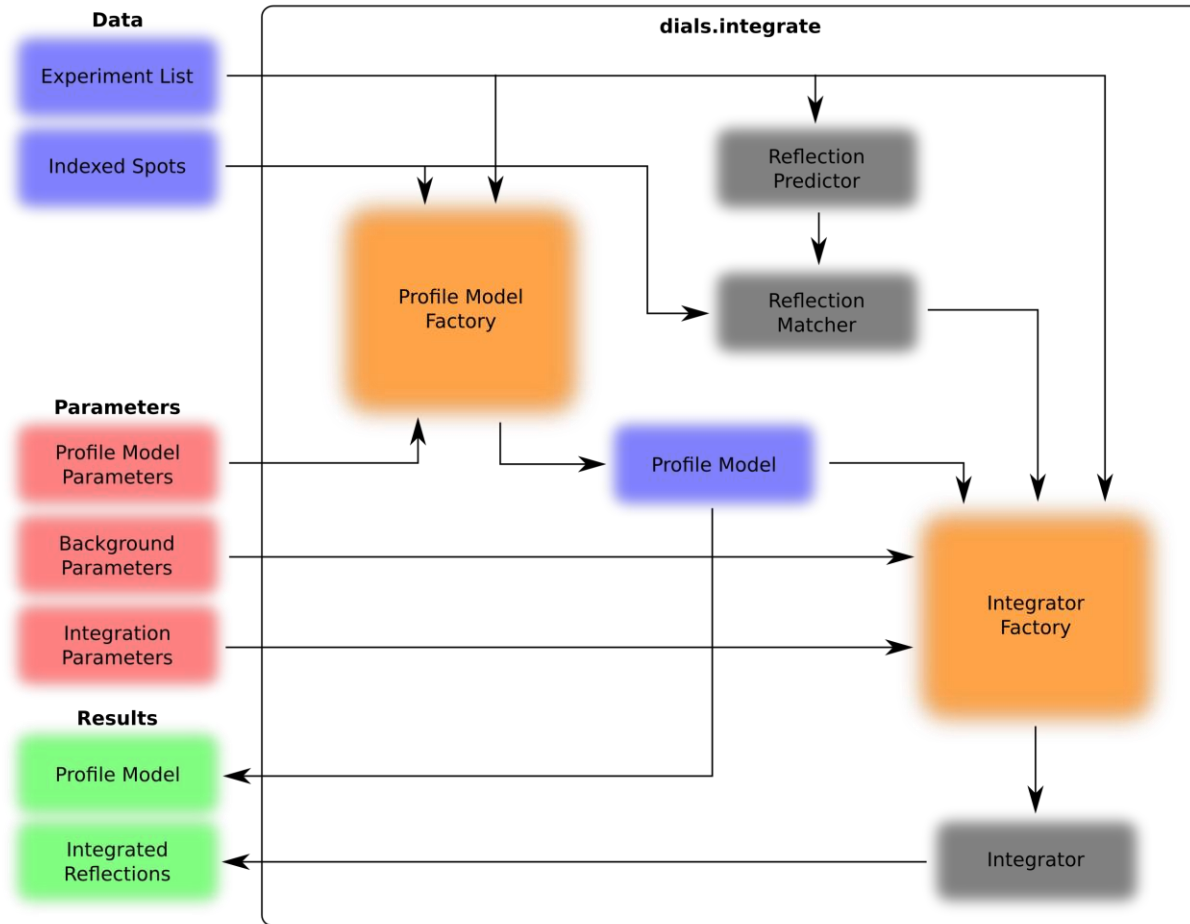
Build reference profiles across all images



Integrate the reflections and save output



Internals: top-level



Internals: types of integrator

3D Integrator

Each integration job reads a block of images and extracts reflections into 3D shoeboxes for processing.

Flattened 3D Integrator

Each integration job reads a block of images and extracts 3D shoeboxes which are “flattened” for processing.

2D Integrator

Each integration job reads a block of images and extracts partial reflections into 2D shoeboxes for processing.

Single Frame 2D Integrator

Each integration job reads a single image and extracts partials reflections into 2D shoeboxes for processing.

Stills Integrator

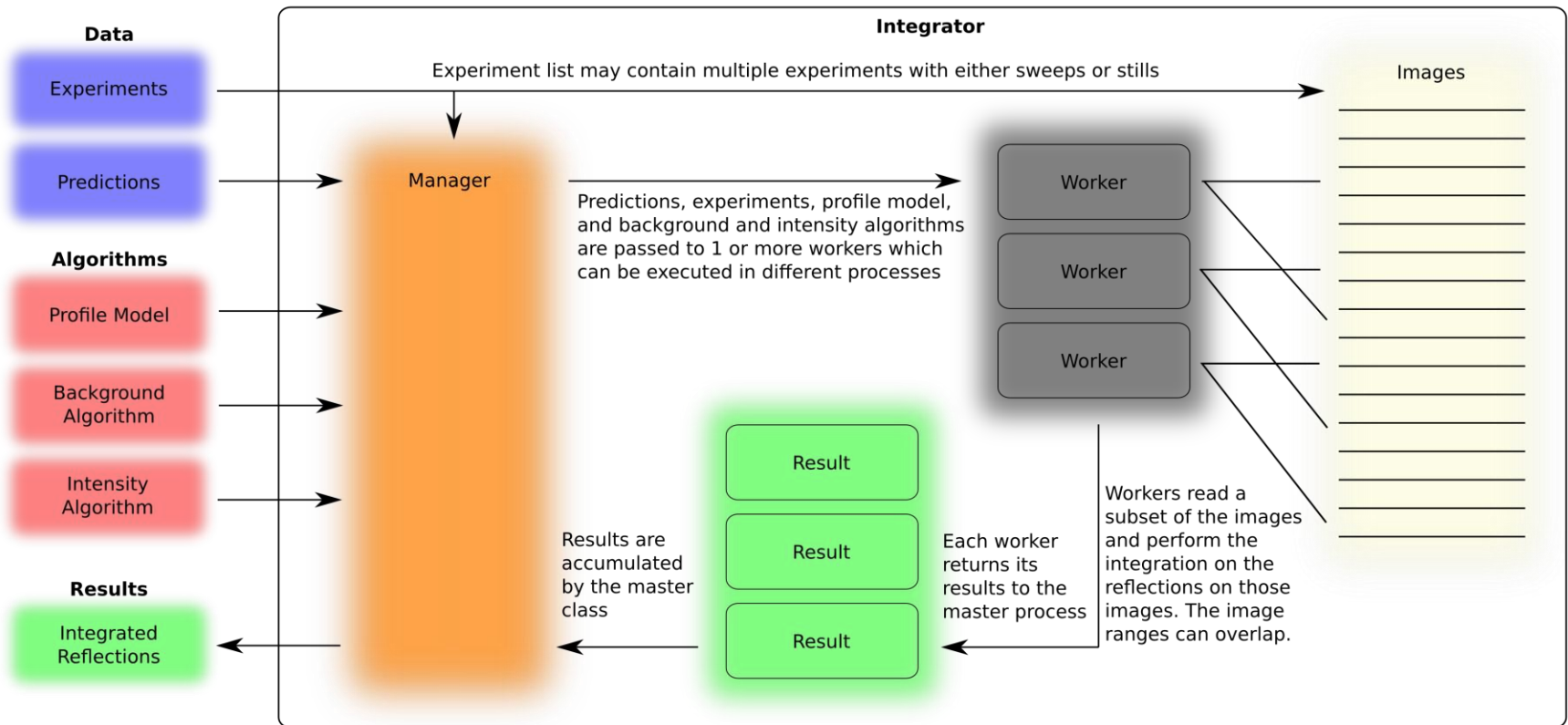
Same as the single frame 2d integrator but specialized to accept still experiments rather than rotation experiments.

Integrator

```
graph LR; A[3D Integrator] --- B[Integrator]; C[Flattened 3D Integrator] --- B; D[2D Integrator] --- B; E[Single Frame 2D Integrator] --- B; F[Stills Integrator] --- B;
```



Internals: integrator

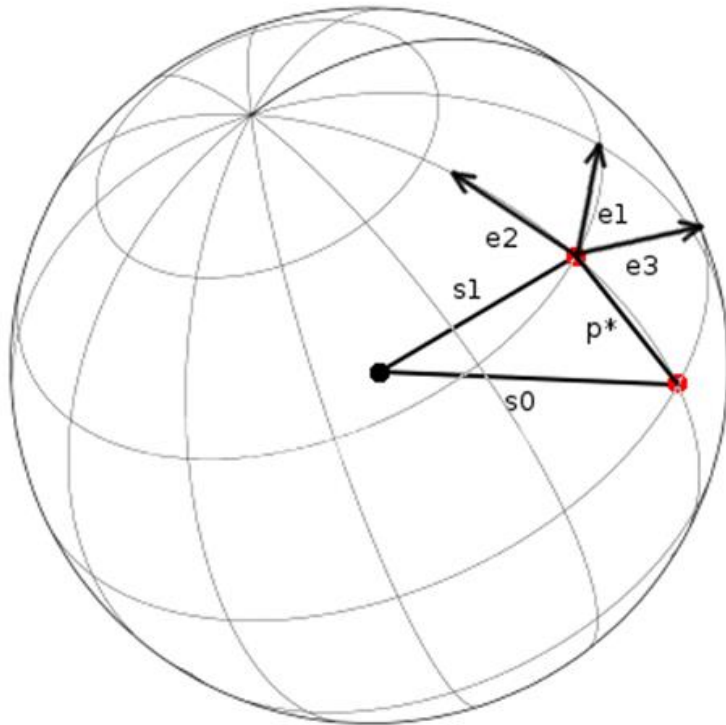


DIALS: integration

REFLECTION SHOEBOXES



Computing reflection shoeboxes



Profile coordinate system

Use the kabsch model of a normal distribution on the surface of the Ewald sphere

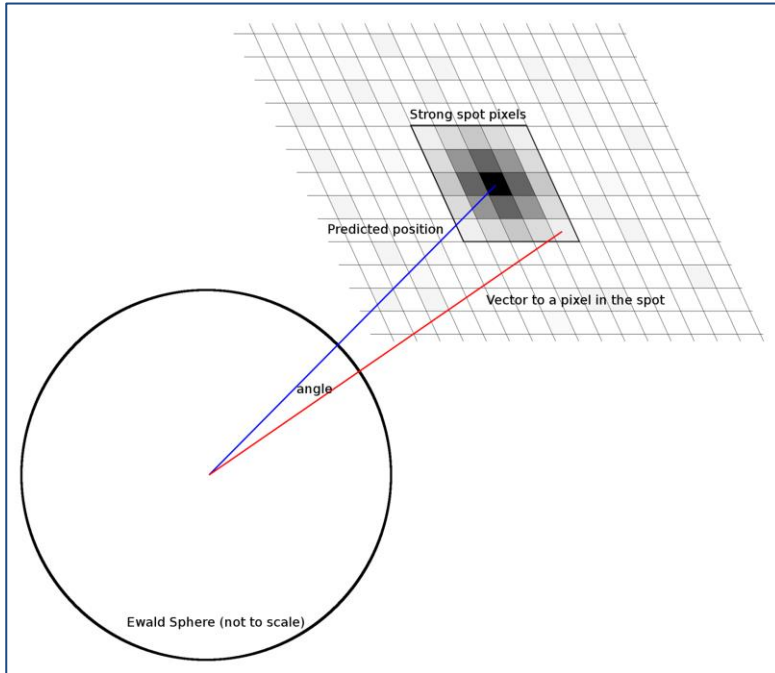
$$\exp\left(\frac{-\epsilon_1^2}{2\sigma_D^2}\right) \exp\left(\frac{-\epsilon_2^2}{2\sigma_D^2}\right) \exp\left(\frac{-\epsilon_3^2}{2\sigma_M^2}\right)$$

$$\mathbf{e}_1 = \mathbf{S}_1 \times \mathbf{S}_0 / |\mathbf{S}_1 \times \mathbf{S}_0|$$

$$\mathbf{e}_2 = \mathbf{S}_1 \times \mathbf{e}_1 / |\mathbf{S}_1 \times \mathbf{e}_1|$$

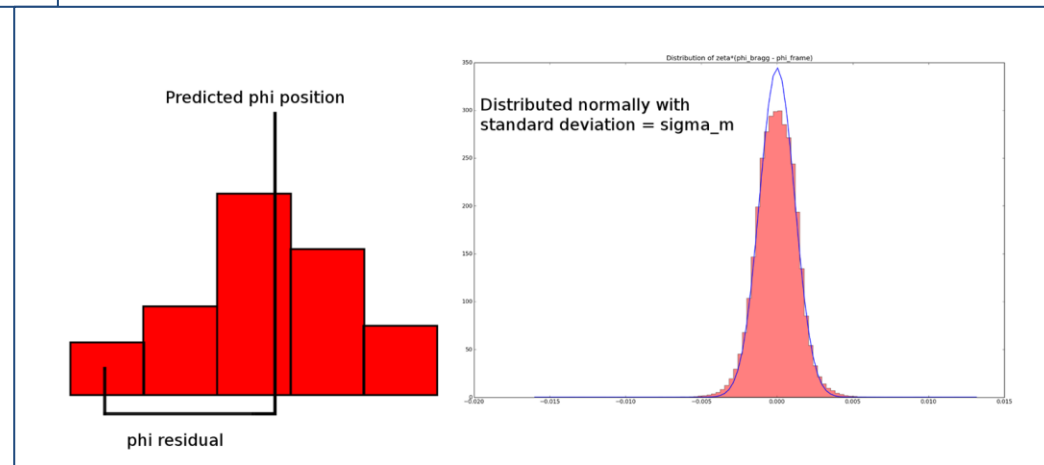
$$\mathbf{e}_3 = (\mathbf{S}_1 + \mathbf{S}_0) / |\mathbf{S}_1 + \mathbf{S}_0|$$

Computing reflection shoeboxes



σ_D is calculated from the spread of angles between the predicted diffracted beam vector and the vector for each strong pixel in the spot

σ_M is calculated by maximum likelihood method assuming a normal distribution of phi residuals for each strong pixel in the spot

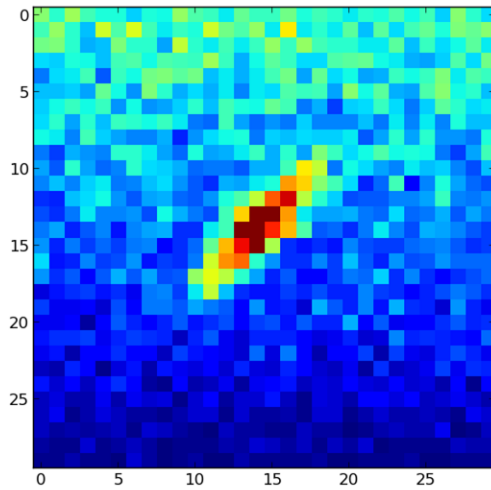


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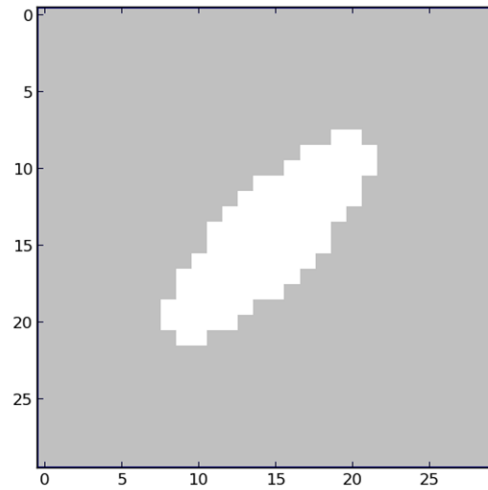
BACKGROUND MODELLING



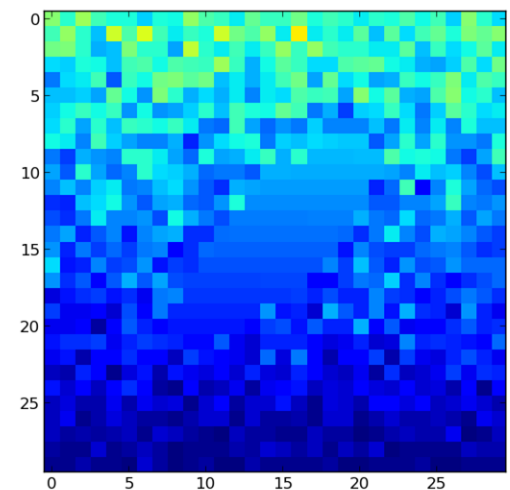
Background determination



Reflection data



Reflection mask



Calculated background

Models

- Options to model the background under the peak as either
 - A constant across each image
 - A constant across all images
 - A plane across each image
 - A hyper-plane across all images
- Computed using simple linear least squares

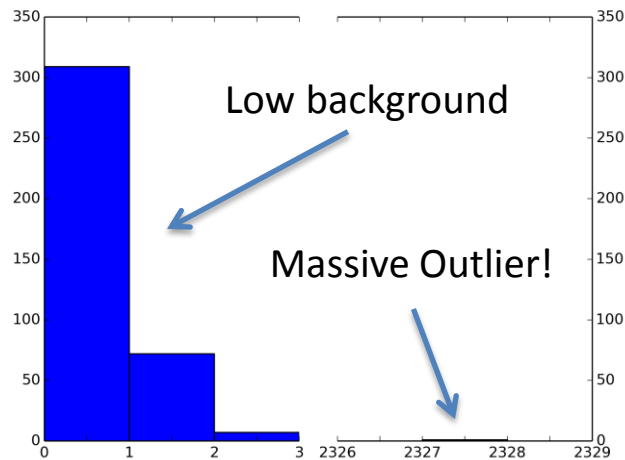
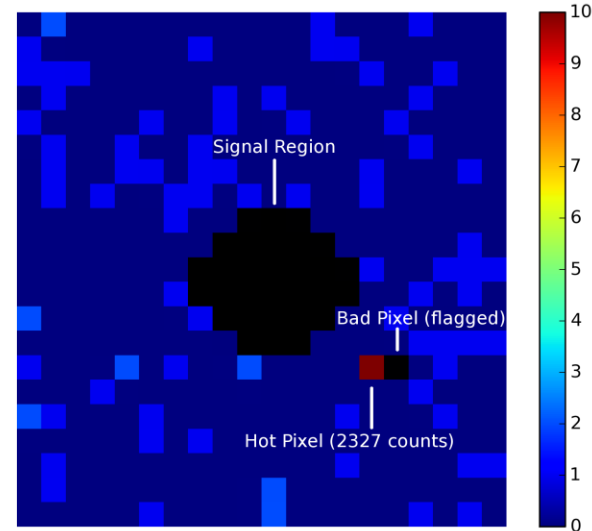
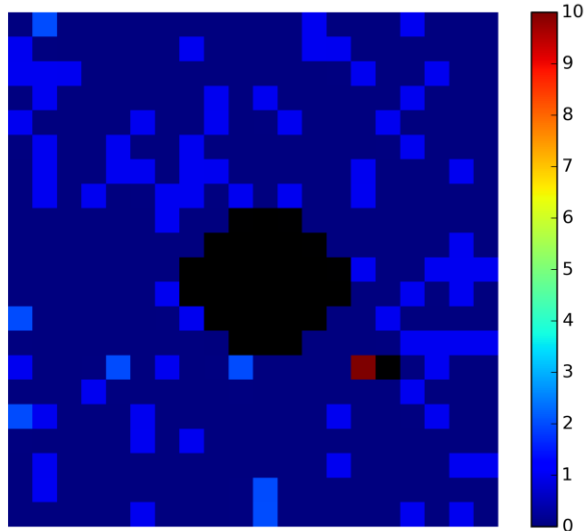


Outliers

- Large valued outliers can cause the background to be over-estimated
- This then causes the reflection intensity to be under-estimated
- Outliers in the background can come from:
 - Intensity from neighbouring spots
 - Hot pixels
 - Zingers
 - Unpredicted reflections
 - Ice rings
 - etc



Outliers

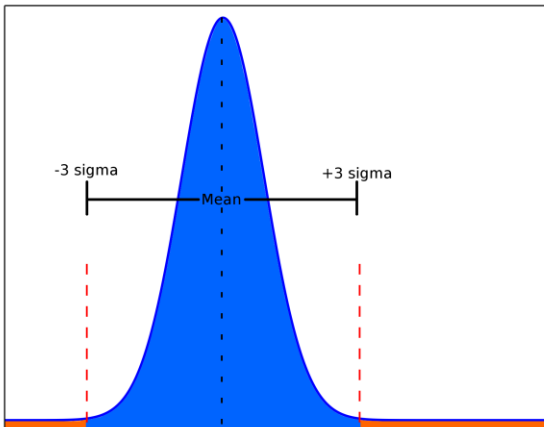


With Hot Pixel		Catastrophic over-estimation!
Mean	6.20	
Variance/Mean	2237.90	Should be ~1 for poisson distribution
Without Hot Pixel		
Mean	0.22	
Variance/Mean	0.926	



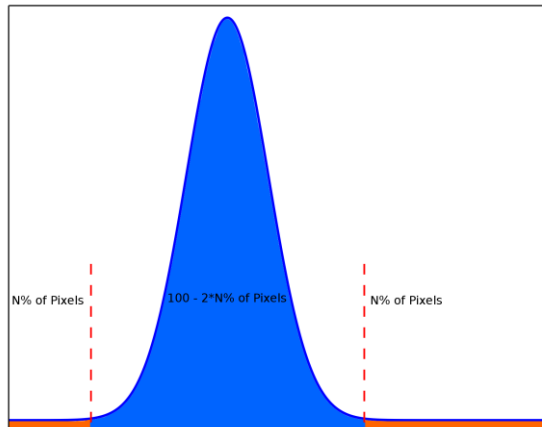
Simple outlier rejection

outlier.algorithm=nsigma



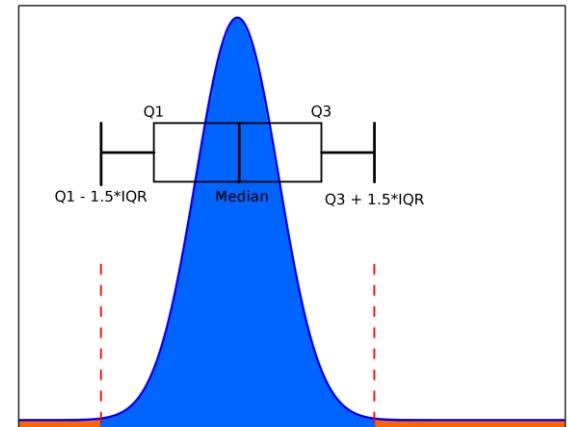
Reject pixels N sigma from the mean

outlier.algorithm=truncated



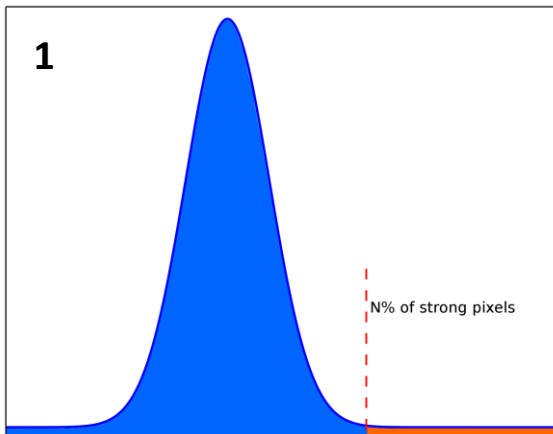
Reject N% of the highest and lowest valued pixels

outlier.algorithm=tukey

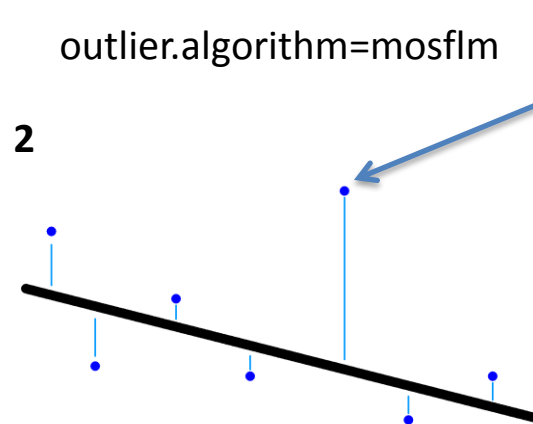


Reject pixels based on the interquartile range

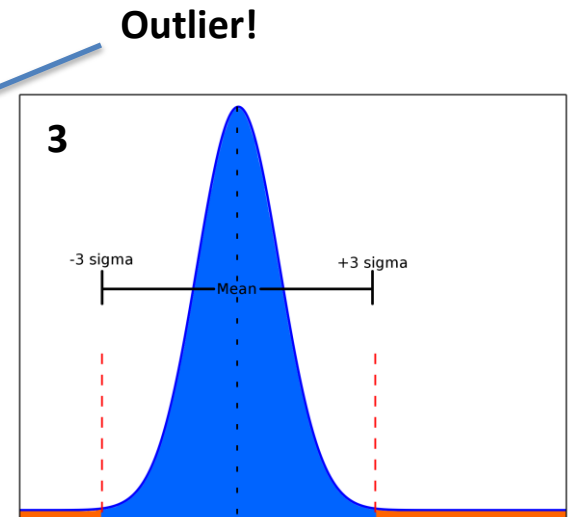
Mosflm-style outlier rejection



Remove N% of strongest pixels and compute the background plane

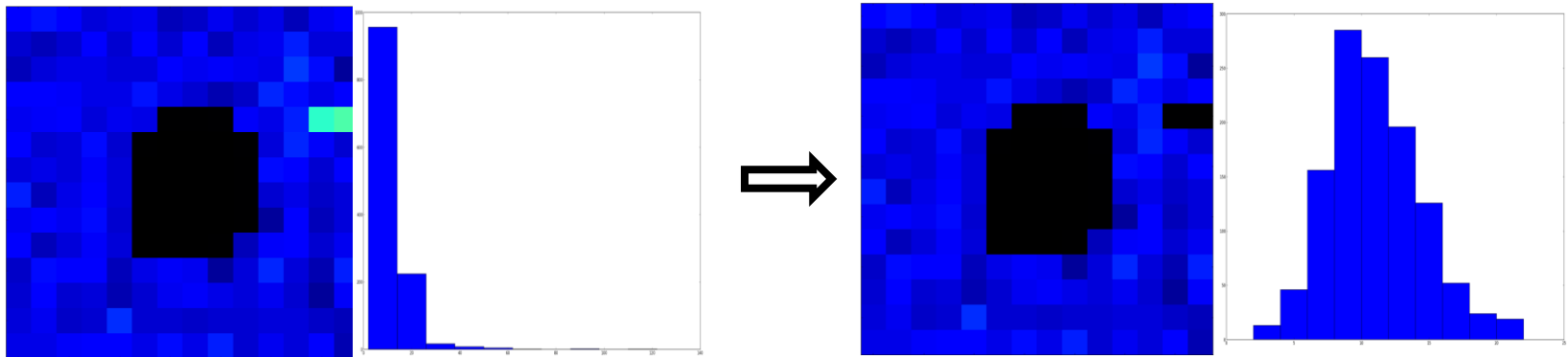


Compute the residuals of all background pixels to the plane



Remove pixels whose residuals are greater than N sigma from the plane

XDS-style outlier rejection



Iteratively remove high valued pixels until the distribution of pixel counts resembles a normal distribution

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SIGNAL INTEGRATION

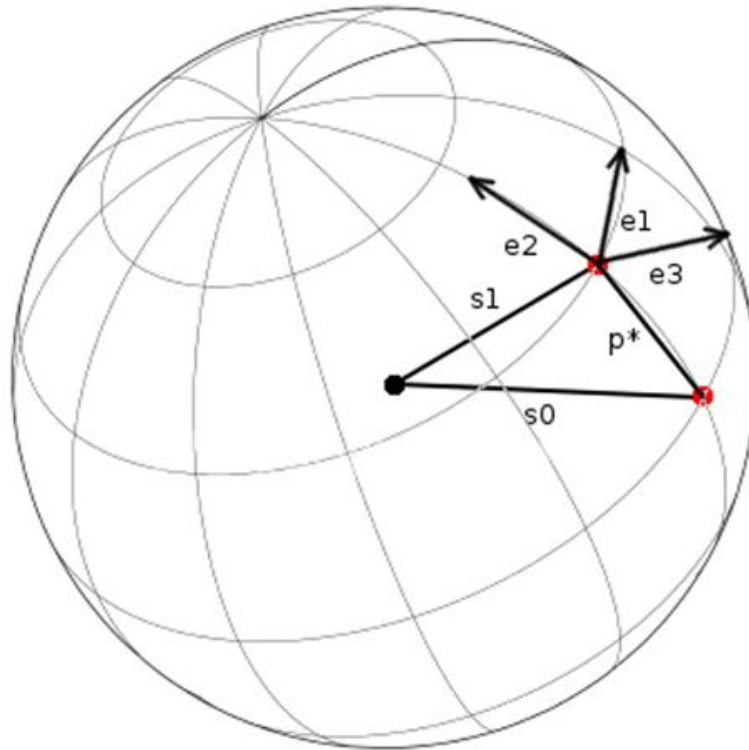


Integration

- Integration algorithm options:
 - Summation
 - 3D profile fitting (as in XDS)
 - 2D profile fitting (future)



3D profile fitting coordinate system



Profile coordinate system

Use Kabsch coordinate system

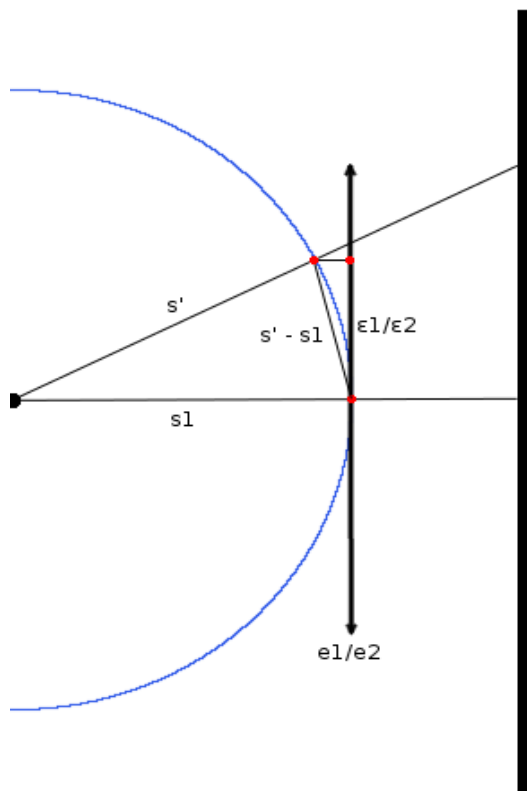
- Corrects for geometrical distortions
- Makes spots appear to have taken shortest path through Ewald sphere
- Model assumes a Gaussian profile in Kabsch coordinate system

$$\mathbf{e}_1 = \mathbf{S}_1 \times \mathbf{S}_0 / |\mathbf{S}_1 \times \mathbf{S}_0|$$

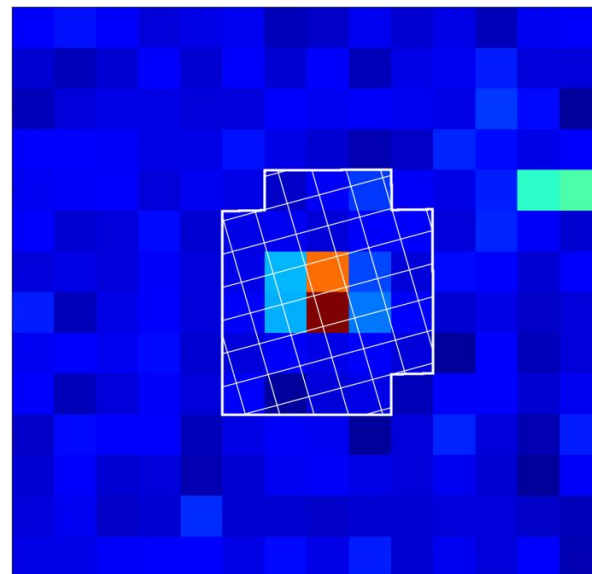
$$\mathbf{e}_2 = \mathbf{S}_1 \times \mathbf{e}_1 / |\mathbf{S}_1 \times \mathbf{e}_1|$$

$$\mathbf{e}_3 = (\mathbf{S}_1 + \mathbf{S}_0) / |\mathbf{S}_1 + \mathbf{S}_0|$$

3D profile fitting pixel gridding

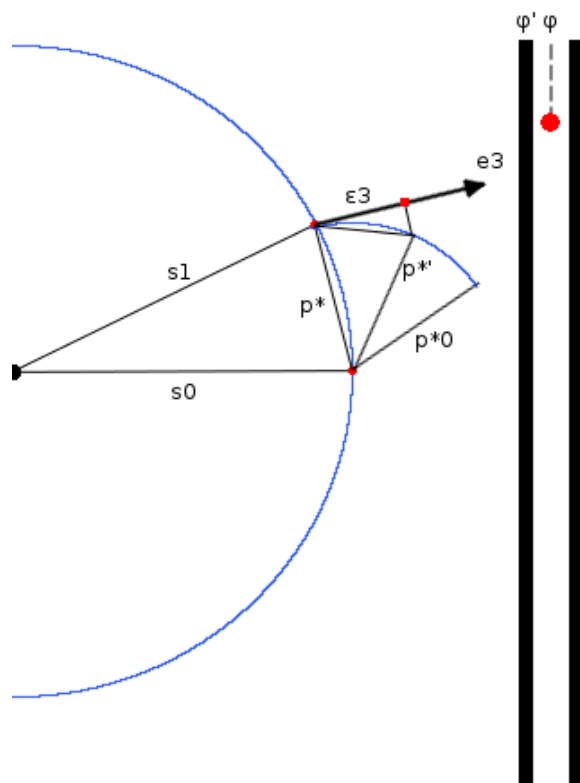


Pixels are mapped to the Ewald sphere

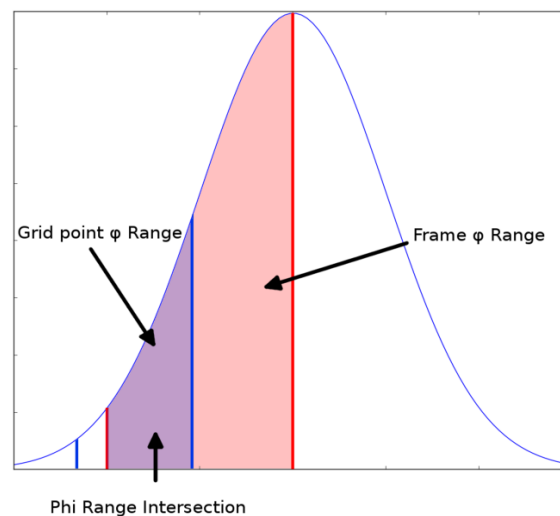


Counts are redistributed to Ewald sphere grid by computing fractional overlap of each pixel and Ewald sphere grid point

3D profile fitting phi gridding

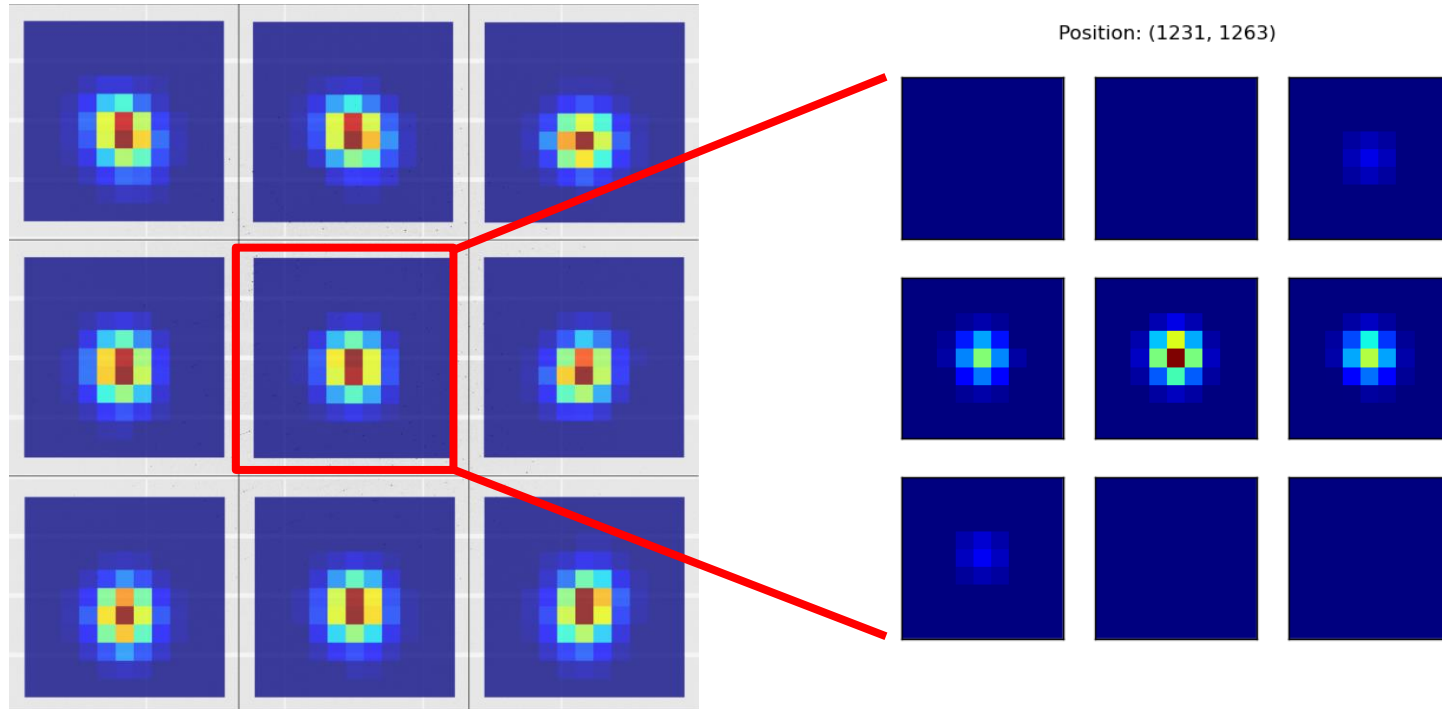


Frames are transformed to make reflection appear as if it took the shortest path through the Ewald sphere



Counts on each image are distributed by finding the angular overlap between each grid point and each image and integrating over the intersection

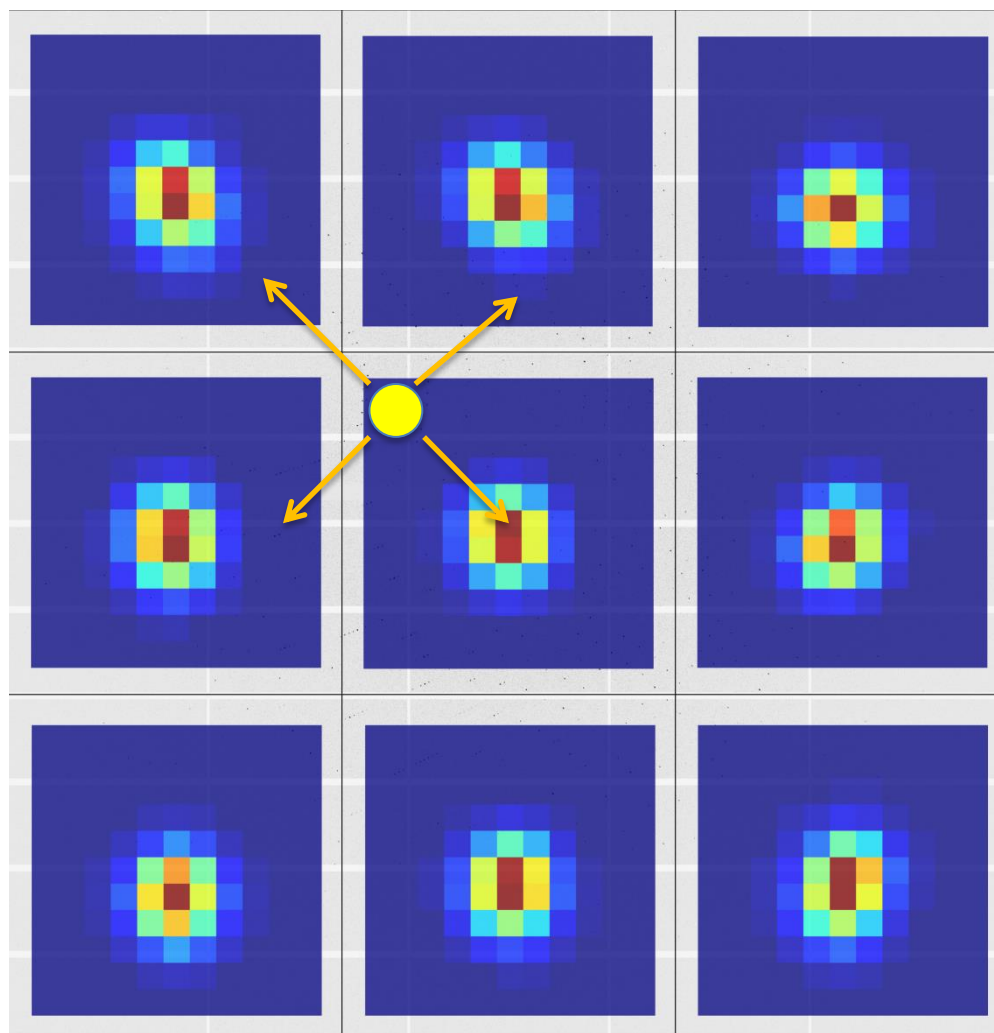
Building reference profiles



- Reference profiles are formed on a grid covering a given angular range
- Grid options include:
 - Rectangular grid (as in Mosflm)
 - Circular grid (as in XDS)
 - Single reflection (currently for multi-panel detectors)

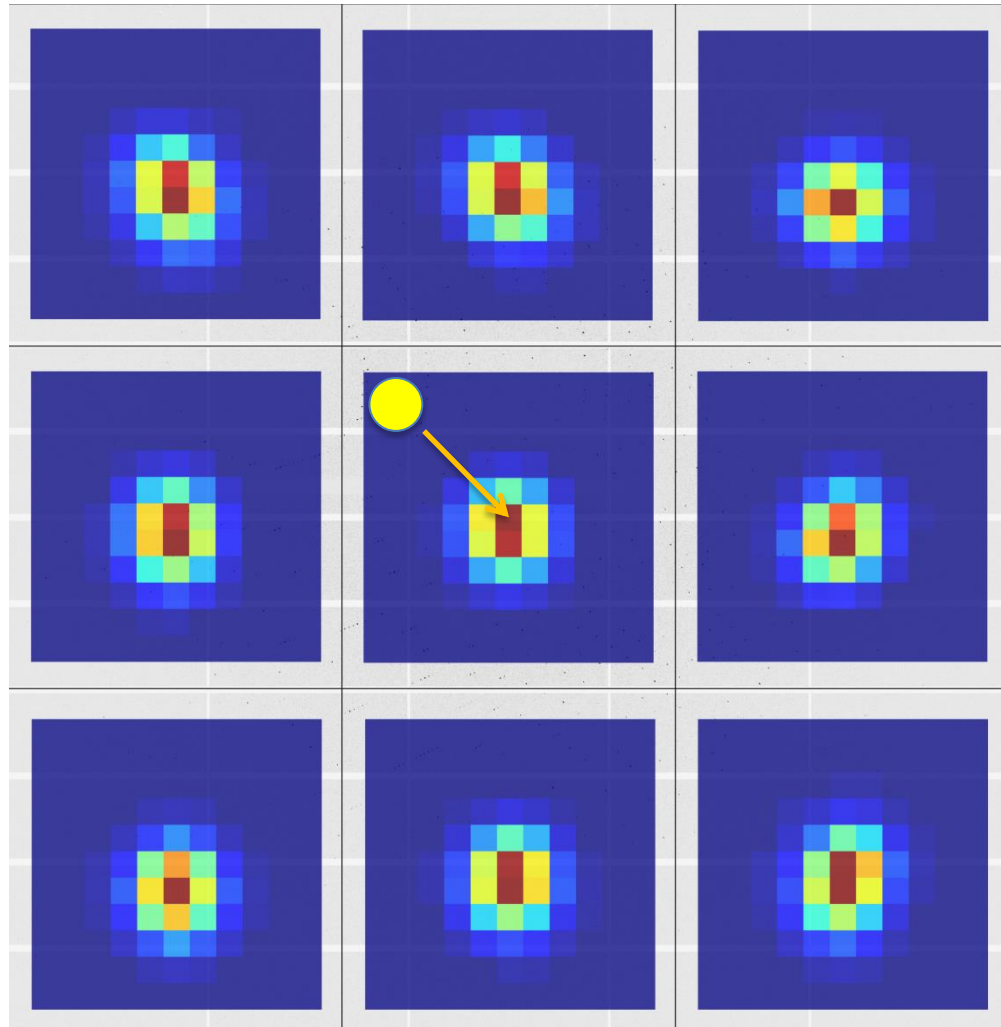
Building reference profiles

Each strong spot contributes to building the profile at adjacent grid points



Fitting reference profiles

Each reflection is fitted against its closest reference profile



Thanks!

